Reduction of Arylsulfonyl Derivatives with the Sm/Cp₂TiCl₂ System. A Novel Method for Preparation of Disulfides†

You Huang, Hongyun Guo, Yongmin Zhang* and Yulu Wangc

^aDepartment of Chemistry, Zhejiang University at Xixi Campus, Hangzhou, 310028, P.R. China.

The Sm/Cp₂TiCl₂ system reduces arylsulfonyl derivatives to the corresponding disulfides in good yield in refluxing THF.

Disulfides are available as starting materials, and are useful as a class of synthetic intermediates in organic synthesis. ^{1–4} Sulfonyl chlorides can be easily and efficiently prepared by chlorosulfonation reactions of arenes and alkanes. ⁵ Therefore, the reduction of sulfonyl chlorides to disulfides is an important process in organic synthesis. As a result many reagents for this purpose have been reported, such as piperdinium tetrathiotungstate, ⁶ sodium cyanoborohydride, ⁷ iodotrimethylsilane, ⁸ aluminium iodide, ⁹ boron triiodide, ¹⁰ and diphosphorus tetraiodide. ¹¹

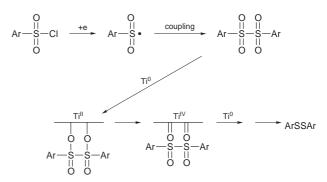
Recently, samarium reagents have been widely applied to organic synthesis, 12 at the same time, many reports in which Cp_2TiCl_2 is used as a catalyst in organic synthesis have been published. 13,14 In our previous work, the Sm/Cp_2TiCl_2 system, which our group has established, is a very effective reducing system. 15,16 In order to investigate the properties of this system and extend the scope of usage further, we thought that samarium and a catalytic amount of Cp_2TiCl_2 might be also a very effective reducing system. Here we report a new procedure for reduction of arylsulfonyl derivatives to the corresponding disulfides with samarium and catalytic amount of Cp_2TiCl_2 (Scheme 1).

$$\begin{array}{ccc} ArSO_2X & \xrightarrow{Sm/Cp_2TiCl_2} & ArSSAr \\ \hline \textbf{Scheme 1} & X = Cl, Br, Na^+ \end{array}$$

To establish the optimum reaction conditions, reduction of *p*-tolylsulfonyl chloride with metallic samarium and various amounts of Cp₂TiCl₂ was examined in THF under a nitrogen atmosphere. Table 1 shows that samarium (2 mmol) with Cp₂TiCl₂ (0.8 mmol) under refluxing THF is the best combination for reduction of *p*-tolylsulfonyl chloride to the corresponding disulfide (entry 5). The reaction also worked well when various amounts of Cp₂TiCl₂ and samarium in refluxing THF (entries 4–7) were used. No reaction occurs with only samarium or Cp₂TiCl₂ (entries 1 and 2) and no reaction takes place with samarium and Cp₂TiCl₂ and room temperature in THF (entry 3).

As shown in Table 2, this system not only can reduce arylsulfonyl chlorides but also can reduce arylsulfonyl bromide (entry 9) and sodium arylsulfinate (entries 10 and 11) efficiently. The reduction of arysulfonyl chlorides containing electronic donating (entry 6) or electronic withdrawing groups (entries 4, 5, 7 and 12) indicate that the electronic environment of aryl group does not influence the reduction. The high yields of the reduction products demonstrate the efficiency of this new method.

Although the mechanism of the reduction process is not clearly defined a possible mechanism is shown in Scheme 2.



Scheme 2

Table 1 Reduction of p-tolylsulfonyl chloride (1 mmol) with metallic samarium and various amounts of Cp_2TiCl_2

| Entry | Sm(mmol) | Cp ₂ TiCl ₂ (mmol) | Reaction conditions | Yield ^a (%) |
|-------|----------|--|-----------------------------|------------------------|
| 1 | 2 | 0 | Reflux 5 h | 0 |
| 2 | 0 | 2 | Reflux 5 h | 0 |
| 3 | 2 | 4 | r.t. 5 h | 0 |
| 4 | 2 | 4 | Reflux 30 min, r.t. 10 min. | 41 |
| 5 | 2 | 0.8 | Reflux 5 h | 86 |
| 6 | 2 | 0.2 | Reflux 5 h | 60 |
| 7 | 2 | 0.1 | Reflux 5 h | 51 |

^a Yield refers to isolated yield of di(p-tolyl) sulfide.

Table 2 Reduction of sulfonyl derivatives to disulfides with ${\rm Sm/Cp_2TiCl_2}^{\it a}$

| Entry | RSO ₂ X | mp/°C (lit.) | Isolated yield (%) |
|-------|--|-------------------------------|-----------------------|
| 1 | 4-MeC ₆ H ₄ SO ₂ Cl | 43-44/44-46 ¹⁷ | 86 |
| 2 | 2-MeC ₆ H ₄ SO ₂ Cl | 36–38/38–39 ^{18a} | 76 |
| 3 | C ₆ H ₅ SO ₂ Cl | 58-59/58-60 ¹⁷ | 83 |
| 4 | 4-BrC ₆ H ₄ SO ₂ Cl | 91–92/93.5 ⁷ | 80 |
| 5 | 4-CIC ₆ H ₄ SO ₂ CI | 68–69/69–71 ¹⁷ | 84 |
| 6 | 4-MeOC ₆ H ₄ SO ₂ Cl | 40-42/41-43 ¹⁷ | 72 |
| 7 | 4-Cl,3-MeC ₆ H ₃ SO ₂ Cl | 48/48–50 ¹⁹ | 84 |
| 8 | 2,4,6-Me ₃ C ₆ H ₂ SO ₂ Cl | 121-123/123-125 ¹⁷ | 79 |
| 9 | 4-MeC ₆ H ₄ SO ₂ Br | 44/44–46 ¹⁷ | 81 |
| 10 | C ₆ H ₅ SO ₂ Na | 59/58–60 ¹⁷ | 73 |
| 11 | 4-MeC ₆ H ₄ SO ₂ Na | 43–45/44–46 ¹⁷ | 77 |
| 12 | Br—SO ₂ CI | 130/131–132 ^{18b} | 76 |

^aAll products gave satisfactory IR and ¹H NMR spectra. *Reaction conditions*: reflux for 5 h.

^bDepartment of Chemistry, Zhejiang Normal University, Jinhua, 321004, P.R. China.

^cDepartment of Chemistry, Henan Normal University, Xinxiang, 453002, P.R. China.

^{*}To receive any correspondence.

[†]This is a **Short Paper** as defined in the Instructions for Authors, Section 5.0 [see *J. Chem. Research (S)*, 1999, Issue 1]; there is therefore no corresponding material in *J. Chem. Research (M)*.

Current available methods have some disadvantages. For example, when sodium cyanoborohydride⁷ is used in the reduction of arylsulfonyl chlorides, although chemoselectivity is observed, the reagents used are relatively expensive and toxic. Iodotrimethylsilane⁸ similarly is very expensive. Piperdinium tetrathiotungstate⁶ can be used under mild conditions, but it is difficult to prepare. The Sm/Cp2TiCl2 system thus offers an attractive alternative to the methods for preparation of disulfides. Its advantages are satisfactory yield, easily available starting materials, simple operation and neutral conditions.

Experimental

A typical procedure for reduction of sulfonyl derivatives is as follows: under a nitrogen atmosphere, 0.30 g (2 mmol) of Sm and 0.20 g (0.8 mmol) of Cp₂TiCl₂ were mixed in 10 ml of THF in a three-necked flask. After stirring under reflux for 15 min, a deep blue solution was obtained. Sulfonyl chloride (1 mmol) in THF (3 ml) was added, the solution turned red at once and the reaction was continued for 5 hours (monitored by TLC), before cooling to room temperature. The solution was then evaporated under reduced pressure, 50 ml of ether and 5 ml of 1 M HCl were added and the solution filtered, the organic layer was then dried over anhydrous sodium sulfate. The solvent was removed in vacuum and the residue was purified by preparative TLC on silica gel (petroleum ether as eluent). Results are summarized

We thank the National Natural Science Foundation of China and the Laboratory of Organometallic Chemistry, Shanghai Institute of Organic Chemistry, Chinese Academy of Sciences for financial support.

Received, 9th September 1998; Accepted, 30th November 1998 Paper E/8/05339A

References

- 1 I. B. Douglas, J. Org. Chem., 1974, 39, 563.
- A. Ogawa, Y. Nishiyama, N. Kambe, S. Murai and N. Sonoda, Tetrahedron Lett., 1987, 28, 3271.
- 3 S. Antebi and H. Alper, Tetrahedron Lett., 1985, 26, 2609.
- 4 S. A. Fontana, C. R. Davis, Y. B. He and D. J. Burton, Tetrahedron, 1996, 52, 37.
- 5 C. M. Suter, The Organic Chemistry of Sulfur, Intrascience Research Foundation, Santa Monica, CA, 1969.
- 6 P. Dhar, R. Ranjan and S. Chandrasekaran, J. Org. Chem., 1990, 55, 3728.
- 7 S. Kagabu, Org. Prep. Proced. Int., 1989, 21, 388.
- 8 P. Kielbasinski, J. Drabowicz and M. Mikolajczyk, J. Org. Chem., 1982, 47, 4806.
- 9 J. R. Babu and M. V. Bhatt, Tetrahedron Lett., 1986, 27, 1073.
- 10 G. A. Olah, S. C. Narang, L. D. Field and R. Karpeles, J. Org. Chem., 1981, 46, 2408.
- 11 H. Suzuki, H. Tani and A. Osuka, Chem. Lett., 1984, 139.
- 12 G. A. Molander, Chem. Rev., 1992, 92, 29.
- 13 Y. Yokomatsu, A. Arakawa and S. Shibuya, J. Org. Chem., 1994, 59, 3506.
- 14 J. Szymoniak, D. Felix and C. Moise, Tetrahedron Lett., 1994,
- 15 Y. M. Zhang, Y. P. Yu and W. L. Bao, Synth. Commun., 1995, **25**. 1825.
- 16 Y. Huang, Y. M. Zhang and Y. L. Wang, Synth. Commun., 1996, **26**, 2911.
- 17 G. Palumbo, M. Parrilli, O. Neri and C. F. R. Caputo, Tetrahedron Lett., 1982, 23, 2391.
- 18 (a) Beilstein's Handbuch der Organischen Chemie, Springer Verlag, Berlin, 1923, Bd. VI, p. 372; (b) ibid. p. 625.
- 19 J. Q. Wang and Y. M. Zhang, Synth. Commun., 1996, 26, 135.